

10050639
01/15/02

U.S. UTILITY Patent Application

PATENT NUMBER and
ISSUE DATE

APPL NUM	FILING DATE	CLASS	SUBCLASS	GAU	EXAMINER
10050639	01/15/2002	436		1765	

**APPLICANTS: Lee Whonchee; Hu Yongjun;

**CONTINUING DATA VERIFIED:

THIS APPLICATION IS A CON OF 09/560,268 04/26/2000
WHICH IS A DIV OF 08/914,935 08/20/1997 PAT 6,074,960

** FOREIGN APPLICATIONS VERIFIED:

PG-PUB DO NOT PUBLISH ☐

RESCIND ☐

Foreign priority claimed ☐ yes ☐ no

35 USC 119 conditions met ☐ yes ☐ no


Verified and Acknowledged Examiners's initials

ATTORNEY DOCKET NO

150.00560104

TITLE : Method and composition for selectively etching against cobalt silicide

U.S. DEPT. OF COMM./PAT. & TM.-PTO-4361 (Rev. 12-94)

NOTICE OF ALLOWANCE MAILED		Assistant Examiner	CLAIMS ALLOWED	
			Total Claims	Print Claim for O.G.
ISSUE FEE		Primary Examiner	DRAWING	
Amount Due	Date Paid		Sheets Drwg.	Figs.Drwg.
 TERMINAL DISCLAIMER 6,074,960		PREPARED FOR ISSUE	Application Examiner	
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